1 79 257/S.ccls. and (dop56 or implants6) same USPAT: US-PGPUB; FRO JPO; ("H. sub.2") same (nitrogen or ("N. sub.2")) Same (nitrogen	I Mumbor	Ui+c	Soarch Toyt	DB	Time stamp
Silicidds same nitride same (hydrogen or ("H.sub.2")) same (nitrogen or ("N.sub.2")) Silicidds same nitride same (hydrogen or ("N.sub.2")) Silicidds same ("N.sub.2") Silicidds same ("N.sub.2	L Number	Hits 79			
("H.sub.2")) same (nitrogen or "PEO, JPC, "N. sub.2")) 2 66 438/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same nitride same (hydrogen or "H.sub.2")) same (nitrogen or "G. JPC, DERMENT; silicid\$6 same nitride same (hydrogen or "H.sub.2")) same (nitrogen or "H.sub.2")) same silicid\$6 with nitride with (hydrogen or "H.sub.2")) same silicid\$6 same nitride same (hydrogen or "H.sub.2")) same silicid\$6 same nitride same (hydrogen or "H.sub.2")) same (nitrogen or "H.sub.2") same silicid\$6 same nitride same (hydrogen or "H.sub.2")) same (nitrogen or "H.sub.2") s	*	, ,			2001,03,21 03.01
C"N.sub.2")) DERWENT; ISM TOB Same Silicid\$6 same nitride same (hydrogen or ("SPGPUB; EPG, JPO; Lower or ("H.sub.2")) same (nitrogen or ("N.sub.2")) sa					
2 66 438/5.ccls. and ((dops6 or implant\$6) same SSERT; 180 TOB					
("M. sub.2")) same (nitrogen or ("M. sub.2")) semiconductor and ((dop\$6 or implant\$6) with silicid\$6 with nitride with (hydrogen or ("M. sub.2")) semiconductor and ((dop\$6 or implant\$6) uSpR7; uS-CPGUB; cFG, JPO; DERWENT; ISM TDB uSPR7; uS-	2	66			2004/09/24 09:54
("M.sub.2")) 2				1	
1 semiconductor and ((dop86 or implant\$6) Swff; with silicid\$6 with nitride with (hydrogen or "H.sub.2")) with (nitrogen or "H.sub.2")) Swff; USPAT;					
1 semiconductor and ((dop86 or implants6) USPAT; USPGUBB; EEO, JPG; USPAT; USPA			("N.sub.2")))	1	
with silicids6 with nitride with (hydrogen or "H.sub.2")) with (nitrogen or "H.sub.2"))	,	1	comicandustar and ((dance on implanted)		2004/00/24 00.55
Or ("H.sub.2")) with (nitrogen or ("EPO, JPO) DERMENT; IBM TDB or ("H.sub.2")) same (nitrogen or ("N.sub.2")) same (nitr	"	Τ.			2004/09/24 09:55
C"N.sub.2"))					į
90					
same silicids6 same nitride same (hydrogen or ("H.sub.2")) same (nitrogen or ("S.copen), epo, ("N.sub.2")) same (nitrogen or ("S.copen), epo, ("N.sub.2")) 8				IBM TDB	
Or ("H.sub.2")) Same (nitrogen or SFO, JPO, DERNENT; TEM TDB USPAT; US-PGPUB; RPO, JPO, DERNENT; TEM TDB USPAT; USP	3	90		USPĀT;	2004/09/24 12:07
Continue				· ·	
S			or ("H.sub.2")) same (nitrogen or		
S			("N.sub.2")))		
US-PCPUB; EPO; JPO; DERWENT; IBM TDB USPAT U		2	(4,000,000,000,000,000,000,000,000,000,0		2004/00/24 12:16
EPO; JPO; DERWENT; IBM TDB USPAT 2004/09/23 10:48 ("4701349").PN. ("4701349").PN. ("4701349").PN. (USPAT; USPAT; USPAT; USPAT; IBM TDB USPAT; USPAT; IBM TDB USPAT;	0	3	(0000049").PN.		2004/09/24 12:16
DERWENT; IEM TDB 2004/09/23 10:48 10:48					
TIM TDB					
- 1649 (("4701349"), PN. - 1649 (438/655).CCLS. - 1649 (438/655).CCLS. - 733 (438/652).CCLS. - 733 (438/652).CCLS. - 733 (438/652).CCLS. - 734 (438/308).CCLS. - 735 (438/308).CCLS. - 307 (438/308).CCLS. - 308 (438/581,583,592,308,652,655,649,651,682.cclsUSPAT; and (dop\$6 or implant\$6) and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and (dop\$6 or implant\$6) with silicid\$6 and (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 and (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 with (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 with (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 with (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silb silicid\$6 with (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silb silicid\$6 with (hydrogen or ("H.sub.2")) - 4738 257/\$.ccls. and ((dop\$6 or implant\$6) with silb silb silb silb silb silb silb silb					
- 1649 (438/655).CCLS. USPAT; US-PGUB; EPO; JPO; DERWENT; IBM TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB USPAT; USPAT USPAT USPAT USPAT USPAT USPAT USPAT USPAT USPAT; USPAT; USPAT USPAT USPAT; USPAT USPAT USPAT; USPAT USPAT USPAT; USPAT USPAT USPAT; USPAT USPAT USPAT; USPAT USPAT USPAT USPAT USPAT USPAT; USPAT USP	-	3			2004/09/23 10:48
US-PGPUB; EPO; JPO; DERWENT; IBM TDB USPAT; USPAT USPA					
- 733 (438/652).CCLS.	-	1649	(438/655).CCLS.	-	2004/09/23 13:50
DERMENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; USPAT USPAT USPAT USPAT USPAT USPAT USPAT;					
TBM TDB		!			
- 733 (438/652).CCLS. (438/652).CCLS. (438/308).CCLS. (438/308).CCLS. (438/308).CCLS. (438/308).CCLS. (438/581,583,592,308,652,655,649,651,682.ccls USPAT; US-PGPUB; EPO; JPO; DERNERNT; IBM TDB USPAT; and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) - 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (nitrogen or ("N.sub.2")) and (nitrogen or ("N.sub.2")) and (nitrogen or ("N.sub.2")) - 4738 257/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) - 27/\$.ccls. and (dop\$6 or implant\$6) with silicid\$6 and (hydrogen or ("H.sub.2")) with (nitrogen or ("N.sub.2")) - 2 ("442901" "4545116").PN. - 2 ("4429011" "4545116").PN 2 ("4429011" "4545116").PN 2 ("4429011" "4545116").PN 2 ("4429011" "4545116").PN 3157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) same (nitrogen or ("N.sub.2")) same (nitrogen or ("N.sub.2")) same (nitrogen or ("H.sub.2")) same (nitrogen or ("N.sub.2"))					
Solution	l	733	(438/652).CCLS.		2004/09/23 13:50
DERMENT; IBM_TDB USPĀT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPĀT USP					
Solution				EPO; JPO;	
- 307 (438/308).CCLS.	l i			-	
Comparison					
Comparison	-	307	(438/308).CCLS.	1	2004/09/23 14:04
DERWENT; IBM TDB 3661 438/581,583,592,308,652,655,649,651,682.ccls USPĀT; and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or EPO; JPO; DERWENT; IBM TDB 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) 4738 257/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) 1 257/\$.ccls. and (dop\$6 or implant\$6) with silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or ("N.sub.2")) 2 2 ("4429011" "4545116").PN. 40 4701349,URPN. 2 2 ("4429011" "4545116").PN. 3 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) 2 2 ("4429011" "4545116").PN. 3 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) 2 3 3 4 2 4 4 4 4 4 4 4 4 4 4 4 4 4 4 4				1	
- 602 438/581,583,592,308,652,655,649,651,682.ccls USPĀT; and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or DERWENT; IBM TDB USPĀT; USPĀRDB; AND (nitrogen or ("N.sub.2")) USPĀT; USPĀT USPĀT; USPĀT USPĀ					
and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) and (nitrogen or EPO; JPO; DERWENT; IBM TDB USPĀT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB USPĀT USPĀT USPĀT USPĀT USPĀT USPĀT 2004/09/23 14:25 USPĀT; USPĀT USPĀT 2004/09/23 14:26 USPĀT; USPĀT 2004/09/23 14:27 USPĀT 2004/09/23 14:26 USPĀT; USPĀT 2004/09/23 14:27 USPĀT; USPĀT 2004/09/23 14:27 USPĀT; USPĀT; USPĀT; USPĀT; USPĀT; USPĀT; USPĀT; USPĀT 2004/09/24 09:53 Same (nitrogen or ("N.sub.2")) US-PGPUB; EPO; JPO; EPO; JPO;					
(hydrogen or ("H.sub.2")) and (nitrogen or DERWENT; IBM_TDB 2004/09/23 14:24 3861 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) US-PGPUB; and (nitrogen or ("N.sub.2")) EPO; JPO; DERWENT; IBM_TDB USPĀT; US-PGPUB; and (nitrogen or ("N.sub.2")) US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPĀT; US-PGPUB; and (nitrogen or ("N.sub.2")) US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPĀT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPĀT USPĀT 2004/09/23 14:25 USPĀT 2004/09/23 14:26 USPĀT 2004/09/23 14:30 USPĀT 2004/09/23 14:30 USPĀT 2004/09/23 14:30 USPĀT 2004/09/23 14:30 USPĀT 2004/09/24 09:53 USPĀT 200	-	602	438/581,583,592,308,652,655,649,651,682.ccl	SUSPAT;	2004/09/23 14:23
C"N.sub.2") DERWENT; IBM TDB USPAT; US					
- 3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2"))			(hydrogen or ("H.sub.2")) and (nitrogen or		
3661 438/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) USPĀT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB USPĀT US-PGPUB; EPO; JPO; DERWENT; IBM TDB USPĀT			("N.sub.2"))		
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and (nitrogen or ("N.sub.2")) - 4738 257/\$.ccls. and (dop\$6 or implant\$6) and silicid\$6 and (hydrogen or ("H.sub.2")) - 1 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 with (hydrogen or ("H.sub.2")) - 1 257/\$.ccls. and ((dop\$6 or implant\$6) with silicid\$6 with (hydrogen or ("H.sub.2")) - 2 ("4429011" "4545116").PN. - 40 4701349.URPN. - 2 ("4429011" "4545116").PN. - 2 ("4429011" "4545116").PN. - 2 ("4429011" "4545116").PN. - 3 ("4429011" "4545116").PN. - 40 4701349.URPN. - 5257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2"))		2001			2004/03/23 14:24
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silicid\$6 and (hydrogen or ("H.sub.2"))					
and (nitrogen or ("N.sub.2")) and (nitrogen or ("N.sub.2")) EPO; JPO; DERWENT; IBM_TDB USPĀT; silicid\$6 with (hydrogen or ("H.sub.2")) with (nitrogen or ("N.sub.2")) - 2 ("4429011" "4545116").PN. 40 4701349.URPN. 2 ("4429011" "4545116").PN. 40 4701349.URPN. 2 ("4429011" "4545116").PN. 157 257/\$.ccls. and ((dop\$6 or implant\$6) same silicid\$6 same (hydrogen or ("H.sub.2")) same (nitrogen or ("N.sub.2"))) EPO; JPO; DERWENT; IBM_TDB USPĀT USPĀT USPĀT 2004/09/23 14:26 USPĀT 2004/09/23 14:26 USPĀT USPĀT 2004/09/23 14:30 2004/09/24 09:53	-	4738			2004/09/23 14:24
DERWENT; IBM_TDB USPAT; US-PGPUB; With (nitrogen or ("N.sub.2")) - 2 ("4429011" "4545116").PN 40 4701349.URPN 2 ("4429011" "4545116").PN 2 ("4429011" "4545116").PN 3 ("4429011" "4545116").PN 40 4701349.URPN 5 ("4429011" "4545116").PN 5 ("4429011" "4545116").PN 6 ("4429011" "4545116").PN 7 ("4429011" "4545116").PN 8 ("4429011" "4545116").PN 9 ("4429011" "4545116").PN 157 (257/\$.ccls. and ((dop\$6 or implant\$6) same same (nitrogen or ("H.sub.2")) - 157 (Silicid\$6 same (hydrogen or ("H.sub.2")) - 158 (Silicid\$6 same (nitrogen or ("N.sub.2")) - 159 (Silicid\$6 same (hydrogen or ("H.sub.2"))			silicid\$6 and (hydrogen or ("H.sub.2"))		
1 257/\$.ccls. and ((dop\$6 or implant\$6) with USPAT; Silicid\$6 with (hydrogen or ("H.sub.2")) US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT US			and (nitrogen or ("N.Sub.2"))		
- 2 ("4429011" "4545116").PN.					
Silicid\$6 with (hydrogen or ("H.sub.2"))	_	1	257/\$.ccls. and ((dop\$6 or implant\$6) with		2004/09/23 14:25
with (nitrogen or ("N.sub.2"))) - 2 ("4429011" "4545116").PN. - 40 4701349.URPN. - 2 ("4429011" "4545116").PN. USPAT 2004/09/23 14:26 2004/09/23 14:27 2004/09/23 14:27 USPAT 2004/09/23 14:30 257/\$.ccls. and ((dop\$6 or implant\$6) same USPAT; 2004/09/24 09:53 silicid\$6 same (hydrogen or ("H.sub.2")) US-PGPUB; same (nitrogen or ("N.sub.2"))) EPO; JPO;		_			
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- 2 ("4429011" "4545116").PN. USPĀT USPĀT 2004/09/23 14:26 - 40 4701349.URPN. USPAT USPAT 2004/09/23 14:27 - 2 ("4429011" "4545116").PN. USPAT 2004/09/23 14:30 - 157 257/\$.ccls. and ((dop\$6 or implant\$6) same USPAT; 2004/09/24 09:53 silicid\$6 same (hydrogen or ("H.sub.2")) US-PGPUB; same (nitrogen or ("N.sub.2"))				1	
- 40 4701349.URPN.			(11440004411 11454545411 1145		0004/55/55
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- 157 257/\$.ccls. and ((dop\$6 or implant\$6) same USPAT; 2004/09/24 09:53 silicid\$6 same (hydrogen or ("H.sub.2")) US-PGPUB; same (nitrogen or ("N.sub.2"))) EPO; JPO;	_	40			
silicid\$6 same (hydrogen or ("H.sub.2")) US-PGPUB; same (nitrogen or ("N.sub.2"))) EPO; JPO;	_	157			
same (nitrogen or ("N.sub.2"))) EPO; JPO;		157			
DERWENT;				DERWENT;	
IBM TDB				IBM TDB	